

# **ELEN E3106/4106 Lecture 5**

## **Carriers: Temperature Dependence, Drift, Mobility, and Resistance**

### Outline

- Temperature effects
- Compensation
- Space charge neutrality
- Mobility & scattering
- Drift velocity & current
- Resistivity

### **Assignments:**

Reading: Streetman and Banerjee §3.3.3-3.3.4, 3.4

Homework 2 due Friday Sept 19<sup>th</sup> by 5pm

# Recap of carrier concentrations

- Recall from Lecture 4, we learned how to get  $e^-$  and  $h^+$  concentrations at:
  - Any \_\_\_\_\_
  - Any \_\_\_\_\_
  - Any \_\_\_\_\_
- We saw that in thermal equilibrium,  $np = \_\_\_\_\_\_$
- And, and  $n_i^2 = n_0 p_0 = N_c N_v e^{-\frac{E_g}{kT}}$ , even when  $n_0 \neq p_0$
- Given the density of states,

$$N_c = 2 \left( \frac{2\pi m_n^* kT}{h^2} \right)^{\frac{3}{2}} \quad N_v = 2 \left( \frac{2\pi m_p^* kT}{h^2} \right)^{\frac{3}{2}}$$

- And we can conveniently find the carrier concentrations,

$$n_0 = n_i e^{(E_F - E_i)/kT} \quad p_0 = n_i e^{-(E_i - E_F)/kT}$$

# Temperature Dependency of *Intrinsic* Carrier Concentrations

- At any given temperature,  $T$ :

$$n_i = \sqrt{N_c N_v} e^{-\frac{E_g}{2kT}}$$

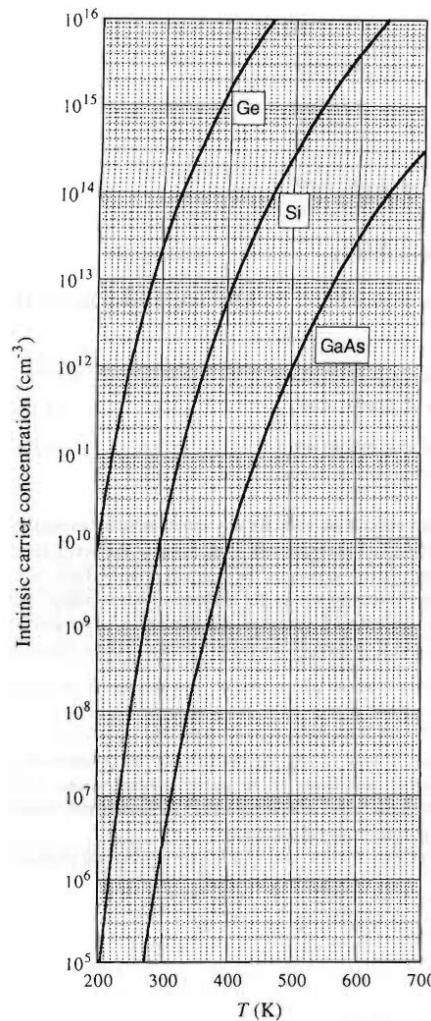
- But it can also be written,

$$n_i(T) = 2 \left( \frac{2\pi kT}{h^2} \right)^{3/2} (m_n^* m_p^*)^{3/4} e^{-E_g/2kT}$$

- What does this tell us?
- $n_i$  is very temperature-sensitive! In silicon,
  - While  $T = 300 \rightarrow 330$  K (10% increase)
  - $n_i = \sim 10^{10} \rightarrow \sim 10^{11} \text{ cm}^{-3}$  (\_\_\_\_ increase)

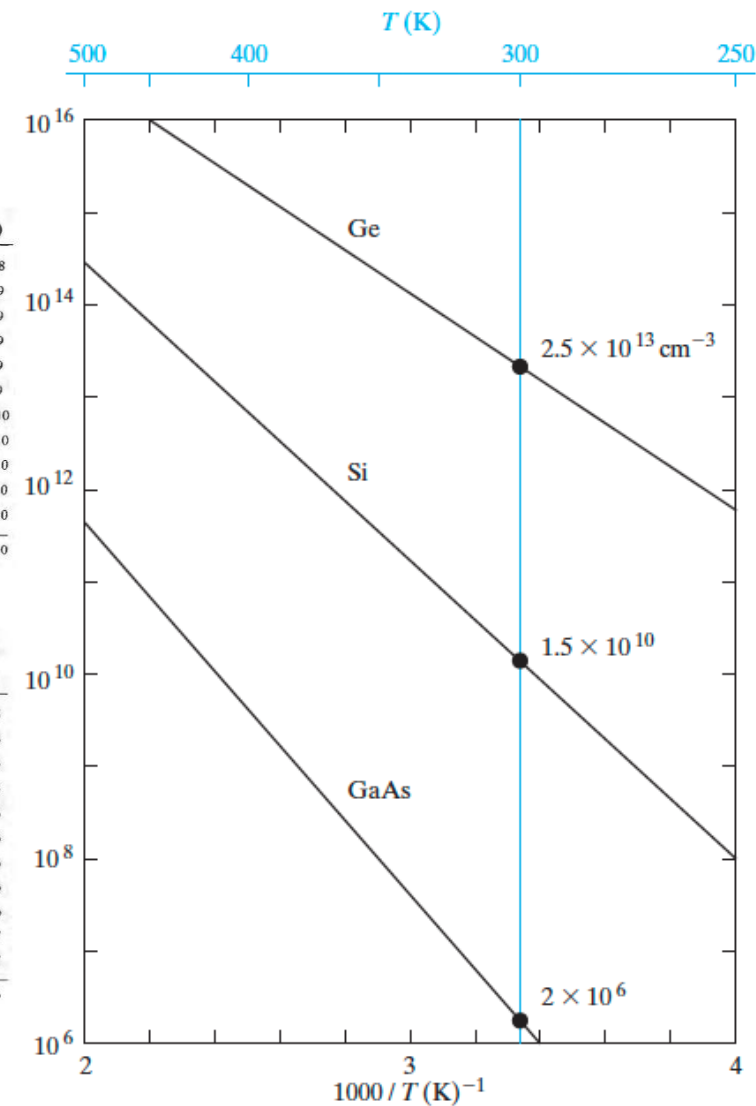
# Visualizing Intrinsic Carrier Concentrations

- Plot  $\log_{10}$  of  $n_i$  vs.  $T$
- What do we expect?
- What is this plot neglecting?



Si	
$T(^{\circ}\text{C})$	$n_i (\text{cm}^{-3})$
0	$8.86 \times 10^8$
5	$1.44 \times 10^9$
10	$2.30 \times 10^9$
15	$3.62 \times 10^9$
20	$5.62 \times 10^9$
25	$8.60 \times 10^9$
30	$1.30 \times 10^{10}$
35	$1.93 \times 10^{10}$
40	$2.85 \times 10^{10}$
45	$4.15 \times 10^{10}$
50	$5.97 \times 10^{10}$
300 K	$1.00 \times 10^{10}$

GaAs	
$T(^{\circ}\text{C})$	$n_i (\text{cm}^{-3})$
0	$1.02 \times 10^5$
5	$1.89 \times 10^5$
10	$3.45 \times 10^5$
15	$6.15 \times 10^5$
20	$1.08 \times 10^6$
25	$1.85 \times 10^6$
30	$3.13 \times 10^6$
35	$5.20 \times 10^6$
40	$8.51 \times 10^6$
45	$1.37 \times 10^7$
50	$2.18 \times 10^7$
300 K	$2.25 \times 10^6$



# Problem: Calculating Intrinsic Carrier Concentration

- If we know  $n_i$  and  $T$ , we have two unknowns: \_\_\_\_\_ and the carrier concentration. If we know one of the two, we can solve for the other:

$$n_0 = n_i e^{(E_F - E_i)/kT}$$

$$p_0 = n_i e^{(E_i - E_F)/kT}$$

- Calculate and show position of the Fermi level in doped Ge ( $10^{16} \text{ cm}^{-3}$  n-type) at  $-15^\circ \text{C}$ , using previous plot

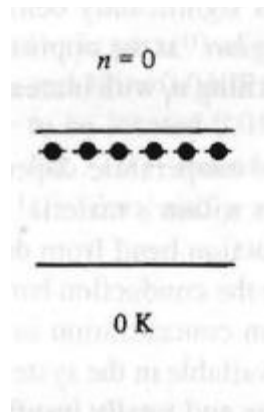
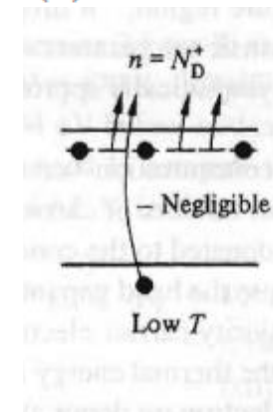
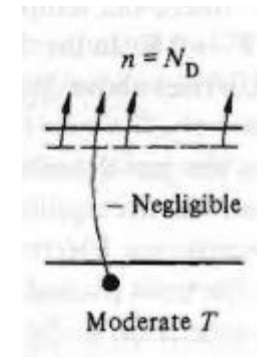
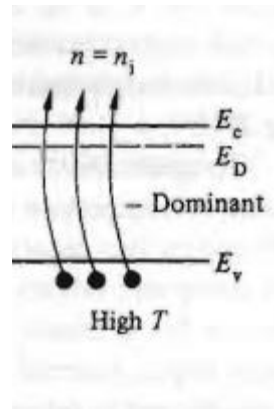
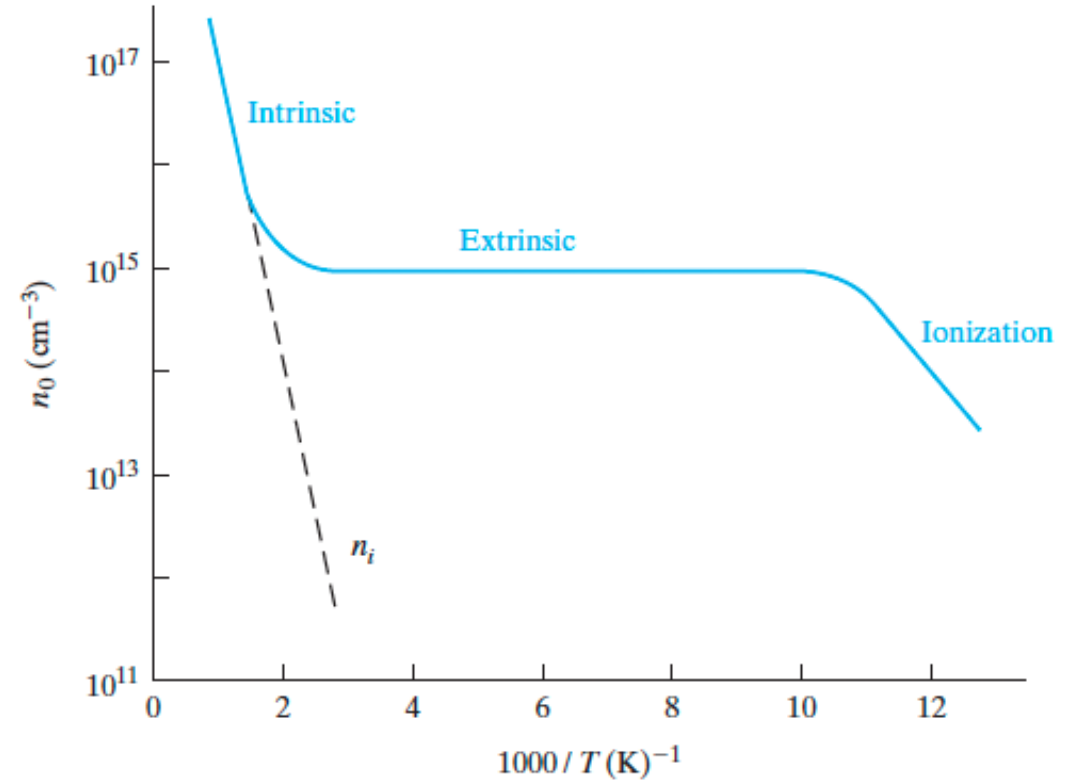
$E_c$  \_\_\_\_\_  
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$E_v$  \_\_\_\_\_

(b) n-type

# Intrinsic Carrier Concentration: Temperature Regions

- \_\_\_\_\_ **Region:** At Low T's, some donors are ionized. By ~100 K all are ionized.
- \_\_\_\_\_ **Region:** At Moderate T's,  $n_0 \approx N_d$  since all donors are ionized and one  $e^-$  obtained for each donor atom
- \_\_\_\_\_ **Region:** At High T's, # of intrinsic carriers is very high and exceeds \_\_\_\_\_



# Compensation

- So far, we have assumed material is doped either n-type or p-type. At moderate temperatures:
  - $n_0 \approx$
  - $p_0 \approx$
- Sometimes we dope semiconductors with both \_\_\_\_\_ and \_\_\_\_\_. This I called compensation.
- You can even start with p-type material and convert a portion of it \_\_\_\_\_ by adding enough donors
- This is a technique frequently employed to make complex devices.
- Essentially, an acceptor can effectively negate the effect of a donor!

# Charge Neutrality

- What if we introduce  $N_d = N_a$ ?
  - The material once again becomes \_\_\_\_\_ and  $n_0 \approx p_0 \approx$  \_\_\_\_\_.
- So far we have seen four types of charged species in a semiconductor:
  - Electrons
  - Holes
  - \_\_\_\_\_ donor ions
  - \_\_\_\_\_ acceptor ions
- In general, this is because we must have charge neutrality in the material
- Any semiconductor material is electrostatically \_\_\_\_\_
  - Positive charge = negative charge

$$n + N_a = p + N_d$$



# Carrier Concentrations in Compensated Semiconductors

- The more detailed equations for finding the carrier concentrations given values for  $N_a, N_d$ :

$$n = \frac{N_d - N_a}{2} + \left[ \left( \frac{N_d - N_a}{2} \right)^2 + n_i^2 \right]^{1/2}$$

$$p = \frac{N_a - N_d}{2} + \left[ \left( \frac{N_a - N_d}{2} \right)^2 + n_i^2 \right]^{1/2}$$

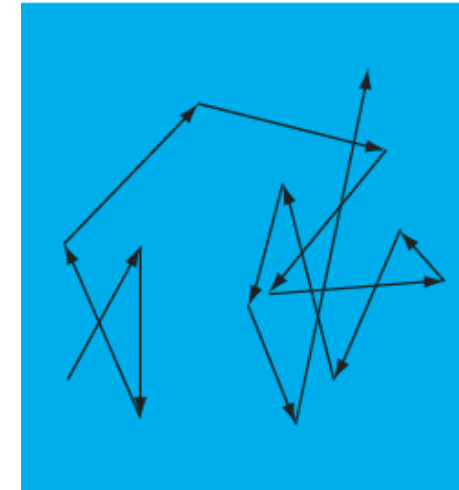
- How do these simplify when  $N_d \gg N_a$ ?

$$n = N_d \quad \text{and} \quad p = n_i^2 / N_d$$

- When is the  $\gg$  approximation valid?

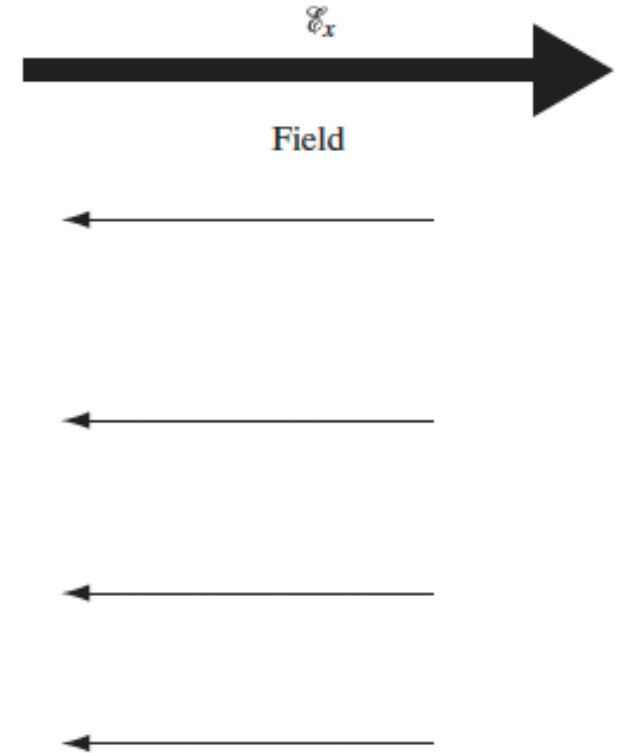
## Carrier Movement: No E-field

- So far, we've examined the effect of doping and temperature on carrier concentrations. We have assumed there is no \_\_\_\_\_
- We know carriers are 'free' to move around. Charge carriers are in constant motion. What does this look like?
- Instantaneous velocity is given by thermal energy:
$$v_{th} = \sqrt{\frac{3kT}{m^*}}$$
- What is the *net* motion of carriers? \_\_\_\_\_
- There is no preferred \_\_\_\_\_ of motion for a group of carriers and no net current flow.
- Mean free time between collisions  $\sim$  \_\_\_\_\_. Mean free distance a few tens of \_\_\_\_\_.



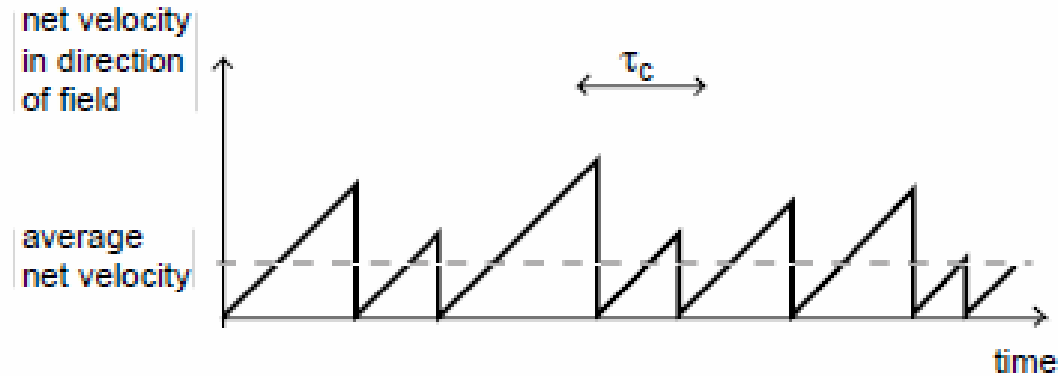
# Carrier Movement: With E-field

- Typically, we need an E-field to make use of semiconductors in devices
- Let's imagine we apply an E-field in the \_\_\_-direction
- What force do  $e^-$  experience?  
 $F = \underline{\hspace{2cm}}$
- Is there net motion of  $e^-$ ?



# Drift

- Drift is the motion of charge carriers caused by an \_\_\_\_\_
- Individual  $e^-$  velocity is \_\_\_\_\_, but the \_\_\_\_\_ velocity is non-zero



- We can assume a mean free time between collisions, \_\_\_\_\_, and that each  $e^-$  loses its entire drift momentum, \_\_\_\_\_, after each collision:

$$p = m_n^* v_n = -qE\tau_c$$
$$v_n = -\frac{qE\tau_c}{m_n^*}$$

# Drift Velocity and Mobility

- The drift velocity is usually written with a proportionality constant,

$$v_n = -\mu_n E$$

- And for holes,

$$v_p = \mu_p E$$

- We call this proportionality constant the \_\_\_\_\_

$$\mu_n = -\frac{q\tau_c}{m_n^*}$$

$$\mu_p = \frac{q\tau_c}{m_p^*}$$

- Describes the \_\_\_\_\_ in a semiconductor.

- Very important quantity!

- Units?

# Mobility

- What are the roles of  $\tau_c$  and  $m^*$ ?
  - If  $m \downarrow$  “lighter” particle means  $\mu \dots$
  - If  $\tau_c \uparrow$  means longer time between collisions, so  $\mu \dots$
- Mobilities at room temperature in \_\_\_\_\_ doped semiconductors:

**TABLE 2–1 • Electron and hole mobilities at room temperature of selected lightly doped semiconductors.**

	Si	Ge	GaAs	InAs
$\mu_n$ (cm <sup>2</sup> /V·s)	1400	3900	8500	30,000
$\mu_p$ (cm <sup>2</sup> /V·s)	470	1900	400	500

- High mobility is desired in devices --> translates to \_\_\_\_\_ (frequencies)

## Problem

Given  $\mu_p = 470 \text{ cm}^2/\text{V} \cdot \text{s}$  for Si, what is the hole drift velocity at  $E = 10^3 \text{ V/cm}$ ? What is  $\tau_c$  and what is the average distance traveled between collisions, i.e., the **mean free path**? Assume 300 K in the dark.

# Mobility and Scattering

- What are the roles of  $\tau_c$  and  $m^*$ ?
  - If  $m \downarrow$  “lighter” particle means  $\mu \dots$
  - If  $\tau_c \uparrow$  means longer time between collisions, so  $\mu \dots$
- Mobilities at room temperature of lightly doped semiconductors:

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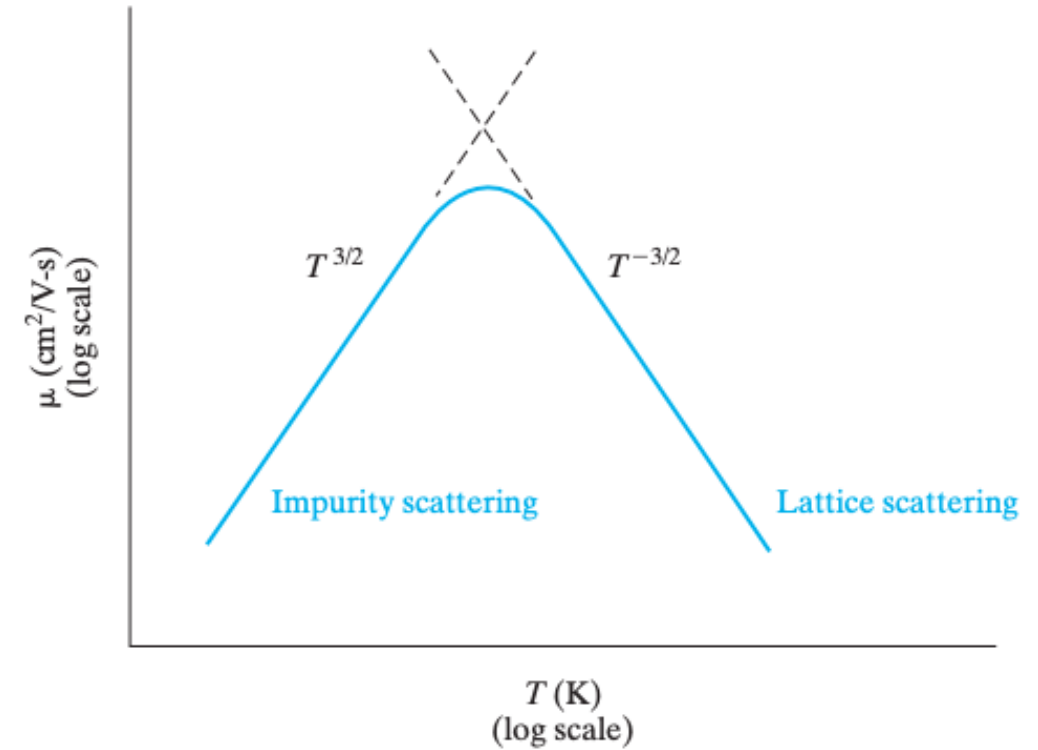
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- High mobility is desired in devices --> translates to higher speeds (frequencies)



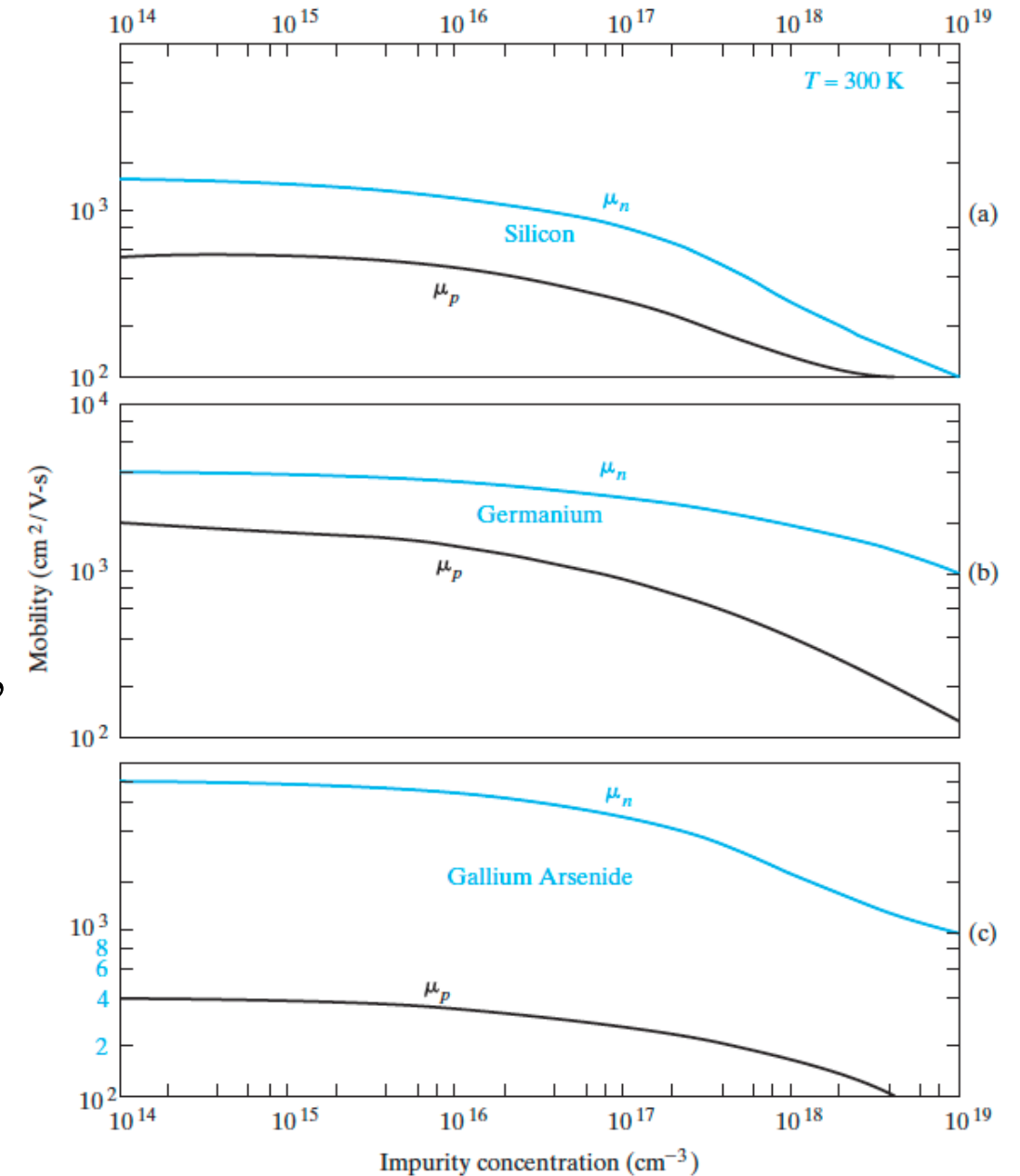
# Effects of Temperature on Mobility

- What does  $\mu$  (through  $\tau_c$ ) depend on?
  - \_\_\_\_\_/lattice scattering (host lattice, like Si)
  - \_\_\_\_\_ (dopant atom) scattering
- How is scattering effected by temperature?
  - Lattice scattering \_\_\_\_\_ with increased temperature, and mobility \_\_\_\_\_
  - Impurity scattering \_\_\_\_\_ with increased temperature, and mobility \_\_\_\_\_
- Strongest scattering (e.g. lowest mobility) dominates total mobility:
$$\frac{1}{\mu} = \frac{1}{\mu_I} + \frac{1}{\mu_L} + \dots$$



# Effects of Doping on Mobility

- We expect the mobility to decrease with total impurities ( $N_a + N_d$ )
- Why? Increased \_\_\_\_\_ scattering!
- As the concentration of dopants increases, the effects of impurity scattering are felt at higher temperatures
- In reality, mobility also depends on \_\_\_\_\_



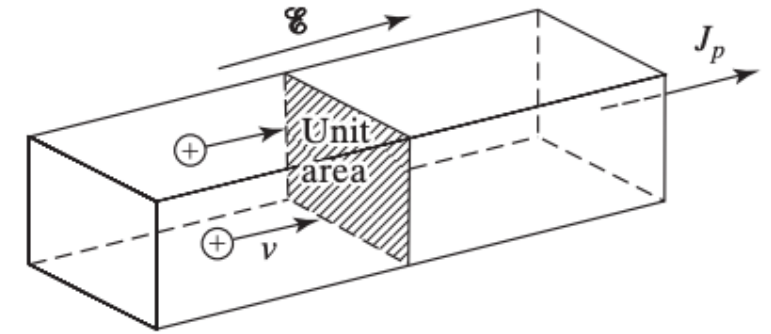
# Drift Current Components

- Recall: we have a net drift velocity of carriers.
- This is \_\_\_\_\_! Now, we can calculate current density, \_\_\_\_\_, for devices!

$$J_n^{drift} = -qn v_{dn} = qn \mu_n E$$

$$J_p^{drift} = +qp v_{dp} = qp \mu_p E$$

- So what is drift current density proportional to?
  - Carrier concentration
  - Carrier drift velocity
  - Carrier charge
- Current density,  $J$ , is the charge per second crossing a unit area plane normal to the direction of current flow (\_\_\_\_\_)



**A p-type semiconductor bar demonstrating the concept of current density.**

# Total Drift Current and Conductivity

- The total drift current density is the \_\_\_\_\_ of the  $e^-$  and  $h^+$  components:

$$J_{\text{drift}} = J_{n,\text{drift}} + J_{p,\text{drift}} = (qn\mu_n + qp\mu_p)\mathcal{E}$$

- Note: This assumes **low E-fields** (typically  $< \text{_____ V/cm}$  in Si)
- The quantity in parenthesis is called the \_\_\_\_\_,

$$\sigma = qn\mu_n + qp\mu_p$$

- Recall: large ratio between majority and minority carriers
  - Usually \_\_\_\_\_ in  $\sigma$

# Resistivity

- Drift current density can therefore be written,

$$J = \sigma E = \frac{E}{\rho}$$

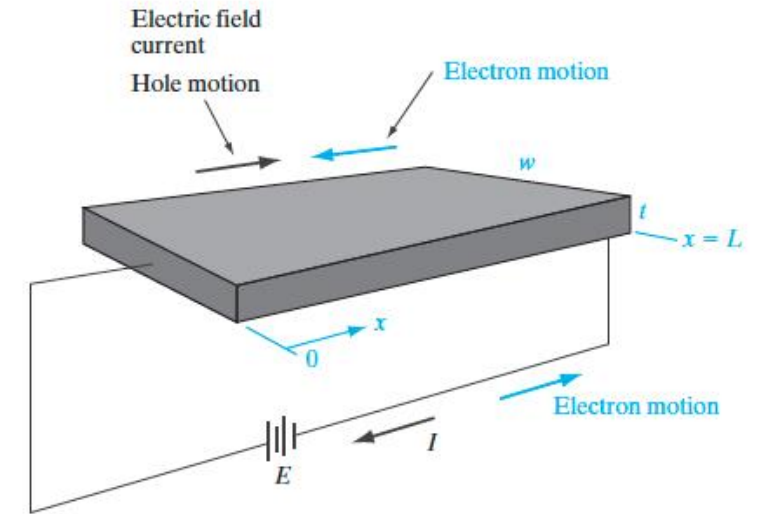
- $\rho$  is the resistivity (i.e. the \_\_\_\_\_ of conductivity),

$$\rho = \frac{1}{\sigma} = \frac{1}{q(n\mu_n + p\mu_p)} \quad \text{Units: } \Omega\text{-cm}$$

- What about when  $n \gg p$ ? (n-type doped sample)
- What about when  $n \ll p$ ? (p-type doped sample)
- We can find the total resistance ( $\Omega$ ) of a bar of semiconductor with a given width, length and thickness (\_\_\_\_\_):

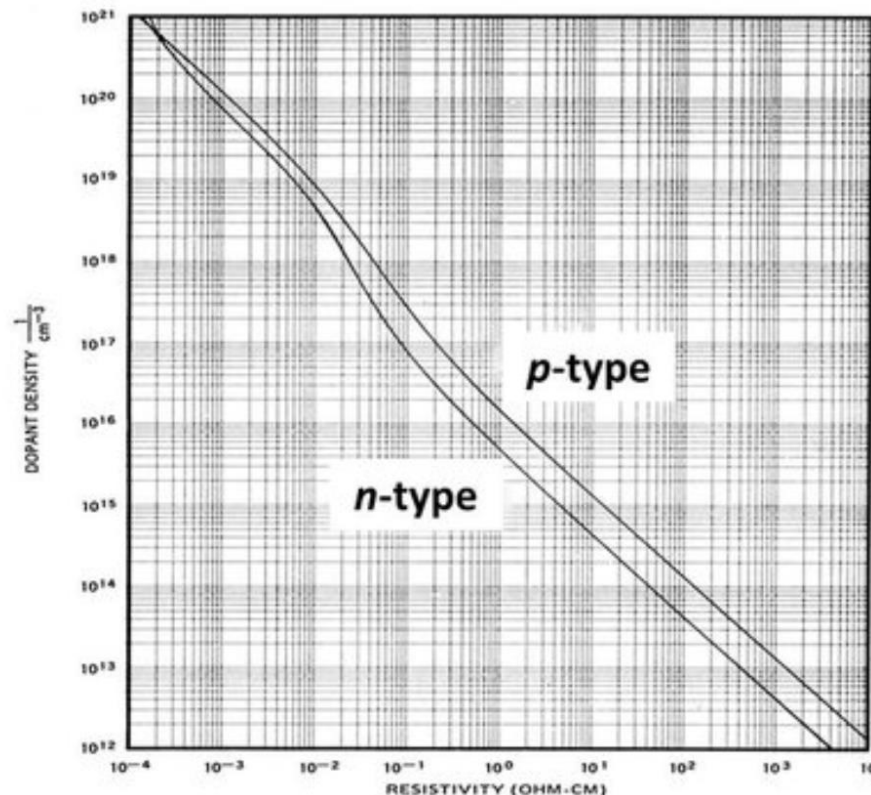
$$R = \frac{\rho L}{wt} = \frac{L}{wt} \frac{1}{\sigma}$$

**Ohm's law: current density is directly proportional to electric field!**



# Resistivity Dependence on Doping

- Experimentally, for Si at room temperature we get the plot below
- We have \_\_\_\_\_ through doping!



For n-type material:

$$\rho \cong \frac{1}{qn\mu_n}$$

For p-type material:

$$\rho \cong \frac{1}{qp\mu_p}$$

**Note:** This plot (for Si) does not apply to compensated material (doped with both acceptors and donors).